OLED & the Status of Its Development

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What is OLED?

- Organic Light Emitting Diode It is:
 - An emissive output
 - No backlight
 - No plasma gasses
 - Self luminous matrix array
 - Created by sandwiching several organic layers between conductors

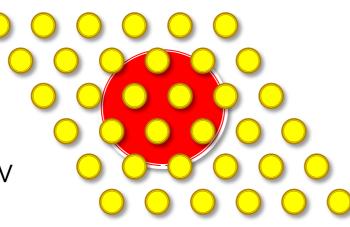
Electroluminescence

Is an optical/electrical process Illumination due to electrical current passing through a material The result of radiative recombination of electrons and holes in a material resulting with an emission of a photon



Semiconductors vs. Organic Materials

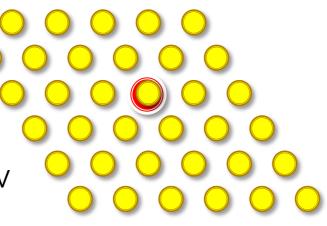
Semiconductor	Organic
 Wannier Excitation 	Frenke
 Typical with inorganic semiconductors 	 Typi mate
 Delocalized over many lattice sites 	 Excitence mole



Binding Energy = -10meV Field Radius = 100Å

Binding Energy = -1meV Field Radius = 10Å

- el Excitation
- cal with organic (molecular) erials
- tation confined to one ecule





Advantages of Organic Conductors

Advantages of organic semiconductors

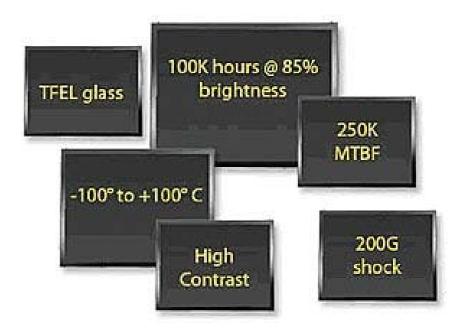
- Electrons reside on P orbitals that are on the same plane and can move freely
- Even field uniformity within the material
- Molecules are held together by weak binding forces
- Carrier mobility is much lower in organic materials
 - typically less than 1cm²/v-s
- High fluorescence efficiencies
- Epitaxy fabrication is not required as is with semiconductors
- Narrow HOMO-LUMO gap in semiconductors will quench light emission.



OLED from the Beginning

1965

- First TFEL developed by Sigmatron
 - Thin Film Electroluminescent Display
- **1**987
 - First QVGA resolution Prototype by Planar
 - Tang/Van Slyke paper on Bi-layer diode
 - Describes how an OLED would work
- **1**993
 - First Multicolored TFEL Prototype by Planar
- **1**997
 - First Color TDEL Prototype by iFire
 - Thick Film Dielectric Electroluminescent
 - Development of white TFEL Prototype by Planar







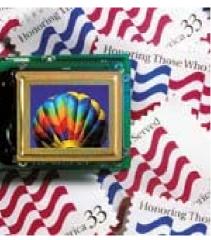
OLED from the Beginning

1999

- First PM-OLED shown by Pioneer
- 2002
 - SVGA Micro-display Prototype by eMagin
- 2003
 - First demonstrated 20 inch WXGA aSi AMOLED by IDTech
 - 2.2 inch AMOLED installed on Kodak LS633 consumer cameras
- 2004
 - First 40 inch panel demonstrated by Seiko Epson
- 2005
 - Second 40 inch panel demonstrated by Samsung
 - AOU starts production of 2.2 inch AMOLED

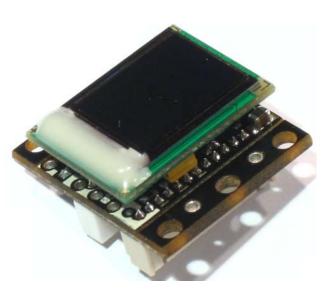














OLED from the Beginning

2006

- Koizumi develops first OLED for lighting
- 2009
 - Microsoft Zune delivers with 3.3 inch AMOLED
 - Google Nexus One delivers 3.7 inch AMOLED
 - SMD develops transparent OLED
 - Mitsubishi demonstrates 155 inch AMOLED
 - Osram starts delivery of Orbeos lamps





SONY

SONY OLED Developments

1994

- Start of initial development
- 2001
 - Demonstration of an SVGA resolution 13 inch at CEATEC Japan

2003

- Display of prototype 24 inch at CES
- 9B¥ investment of OLED manufacturing plant in partnership with Sony Toshiba LCD
- 2004
 - Mass production starts of small OLED (100,000 unit/yr)
 - Display of a 24 inch using tiled 12 inch panels at CES
 - Delivery of the PEG-VZ90 using 3.8 inch 480 x 320 AMOLED







SONY OLED Developments

2007

- Display of 27 inch AMOLED manufactured using laser thermal printing
- 2008
 - Sales of the 11 inch XEL-1 TV
 - First OLED commercially available TV
 - Sony announces \$203M investment in new OLED tooling
- 2009
 - Demonstration of 2.5 flexible display at CES







SONY OLED Developments

2010

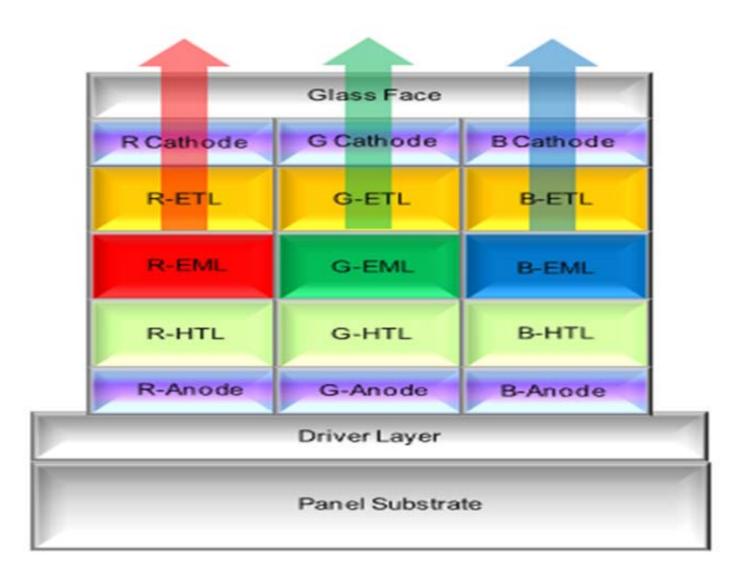
- Demonstrations of a 24.5 inch 3D AMOLED at CES
- Sony shows 24.5 inch AMOLED designed for professional use at SMPTE Technology Conference
- Sony delivers first professional OLED monitor
 - PVM 740
 - 7.4 inch 960 x 540 resolution @ 10 bit

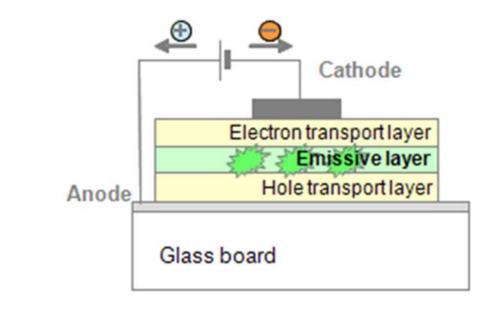


PVM 740



Construction

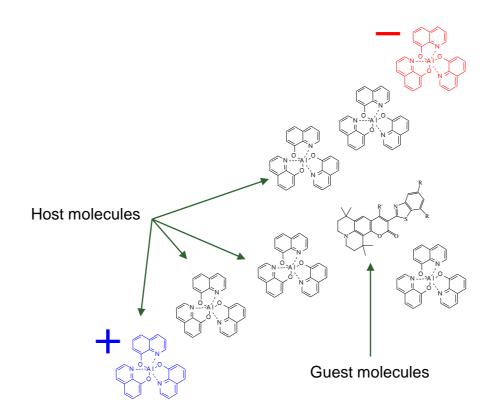


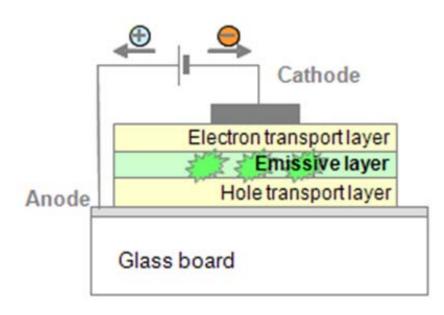






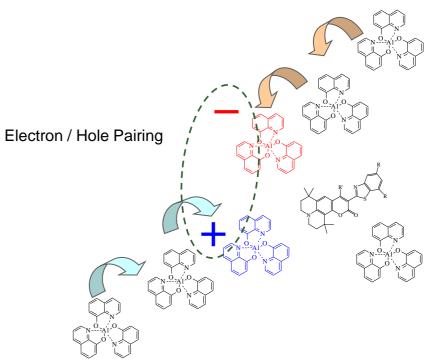
How it Works





1. Electrical charge in emissive layer

Electrons and holes are injected into the emissive layer from electrodes.

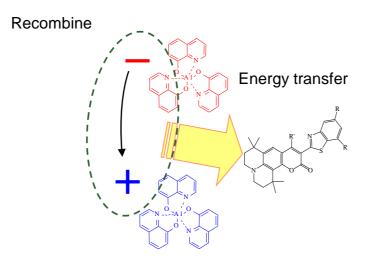


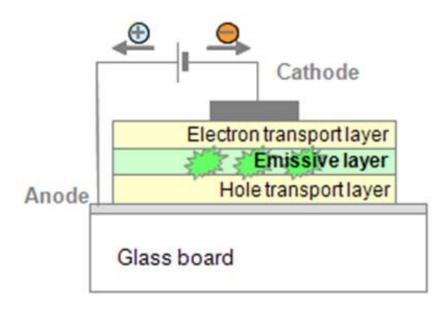
2. The formation of electron-hole pairs through charge transfer

Electron-hole pairs are formed when the injected electrons and holes approach one another while flowing through the emissive layer on host molecules.



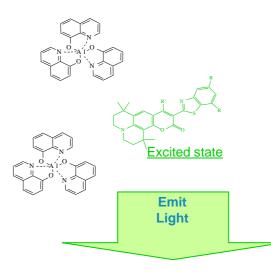
How it Works

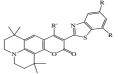




3. Energy transfer to the emitting material (guest molecules)

When electrons and holes recombine in electron-hole pairs, energy is transferred to the guest molecules.





Low-energy ground state

4. Excitation of the emitting material (guest molecules)

Guest molecules are excited by energy transferred from recombining electrons and holes, achieving a state of high energy.

The excited guest molecules emit light, thereby releasing energy and returning to their low-energy ground state

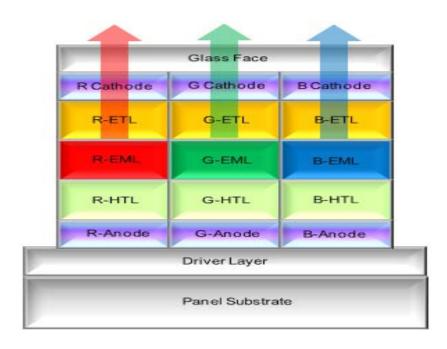


Typical OLED Construction

Substrate Structure

- TFT and drive
- SOG
- Anode
 - Conductive layer
 - Indium Tin Oxide (ITO)
- Hole Transport Layer (HTL)
 - Mixture of ionimars
 - PEDOT/PSS, CuPc, or 1-TNATA

- Emission Layer (EML)
 - Phosphor
 - ppy (green), btp (red), flrpic (blue)
- Electron Transport (ETL)
 - Electron-deficient heterocycles
 - TPBi, Oxadiazole, silole, DBzA, or BCP
- Cathode
 - If transparent , Indium Tin Oxide (ITO)
 - If not, then Mg:Ag or Li-Al





A matter of scale

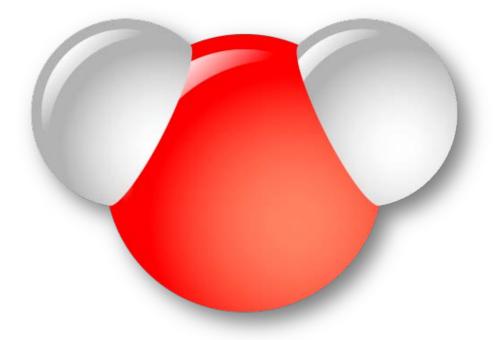
OLED Module

- All layers
- 1.4mm (1/16 inches)
- Substrate Structure
 - 2000Å
- Anode
 - 1800Å
- Hole Injection/Transport
 - ∎ 1200Å

- Emission Layer
 - 800Å
- Hole Blocking Layer
 - 20 40Å
- Electron Injection/Transport
 - 1200Å
- Cathode
 - 3000Å

1Å = 1.0 x 10⁻¹⁰ meters Or = .1nm

In reference The diameter of a water molecule is 29Å





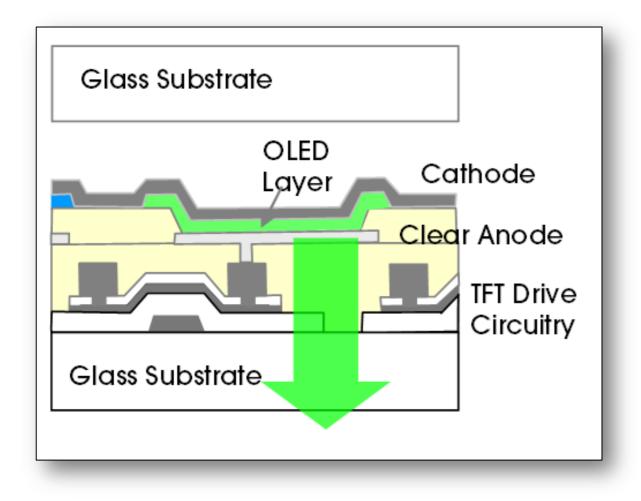
Architecture

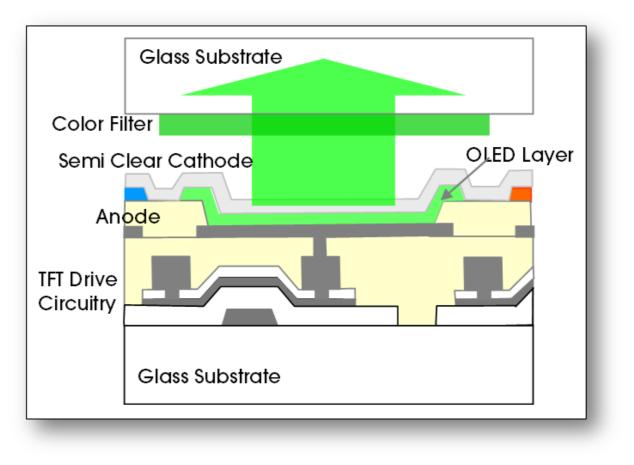
Bottom Emission

- Limited aperture
- Issues with driver density
- More complicated driver fabrication

Top Emission

- Simpler driver design





- Larger emission area
- Much higher emission efficiencies



Types of OLED

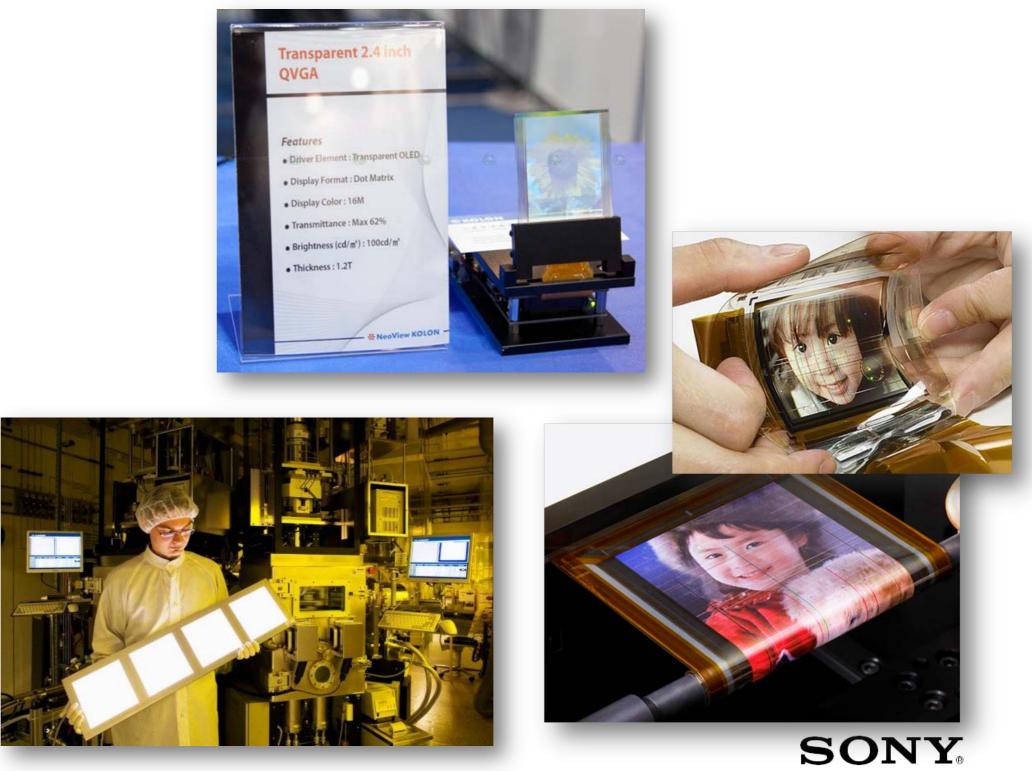
TOLED

- Transparent OLED
- SOLED
 - Stacked OLED
 - used for lighting

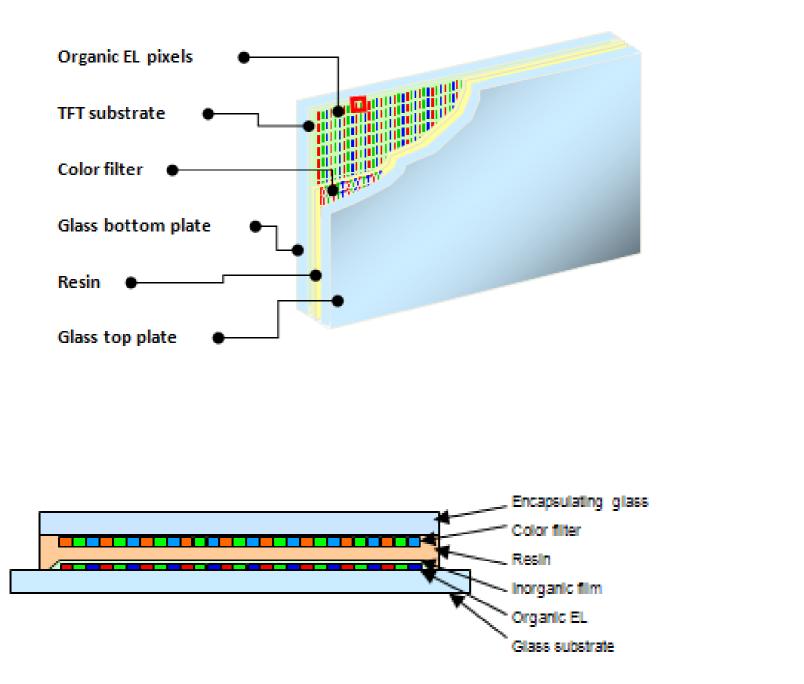
P-LED

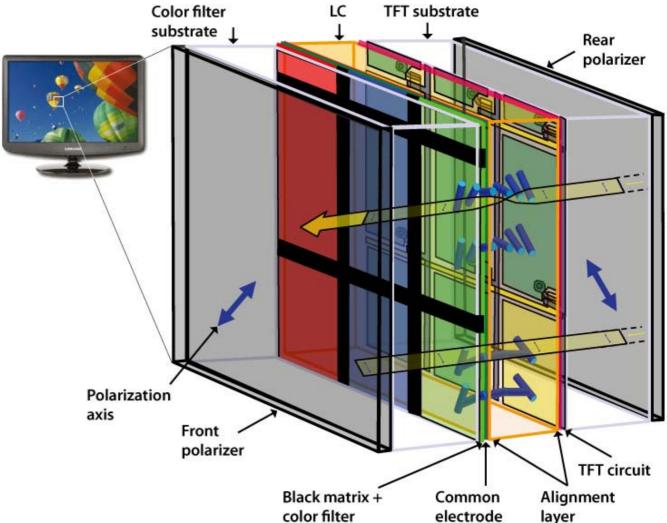
- Polymeric based OLED
- Flexible
- AMOLED
 - Active matrix displays





OLED compared to LCD

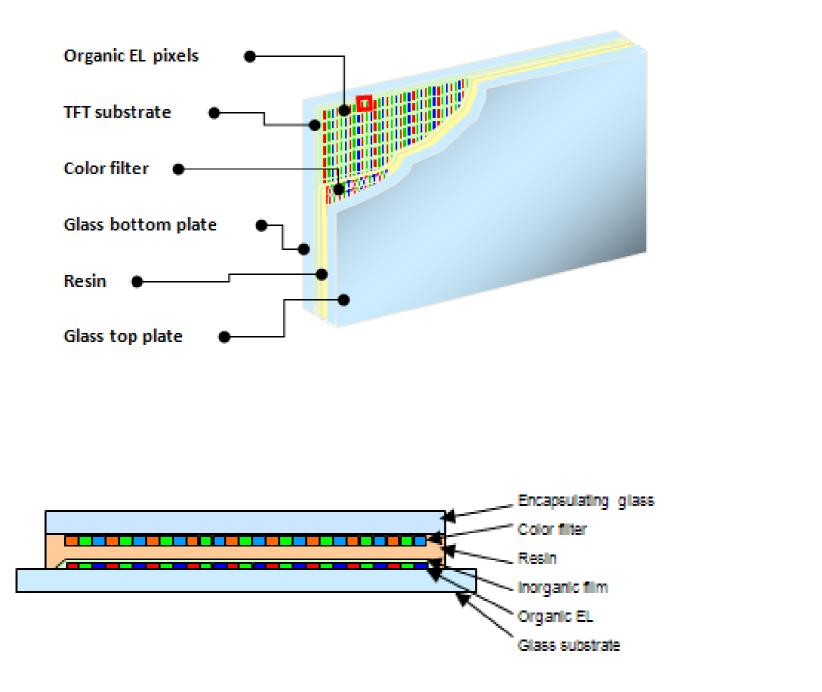


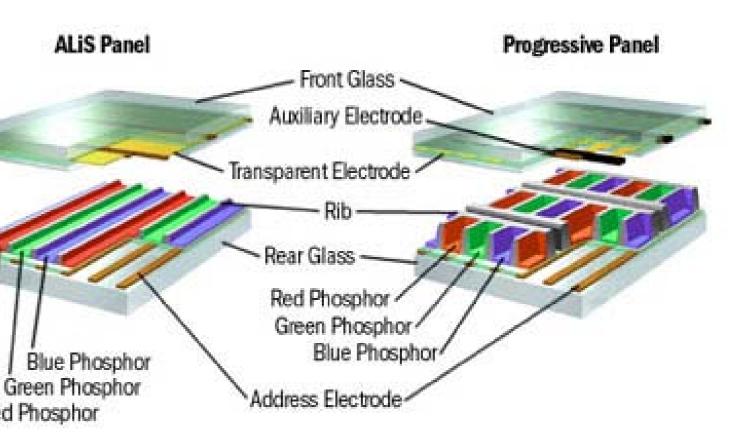




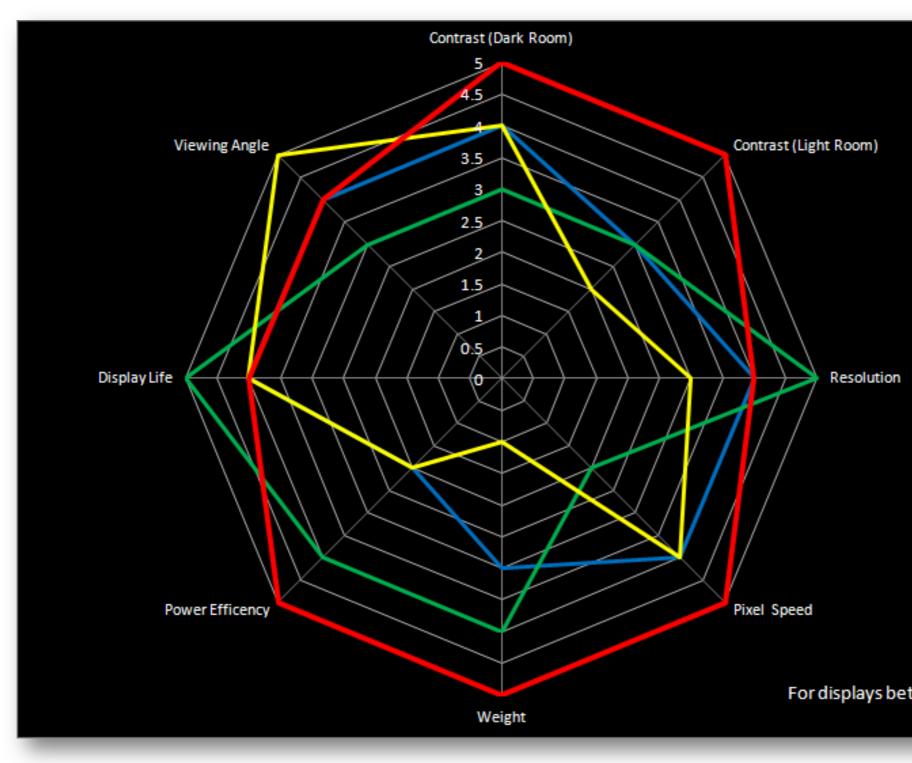
OLED compared to Plasma

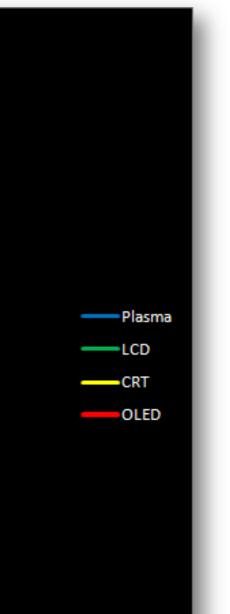
Red Phosphor





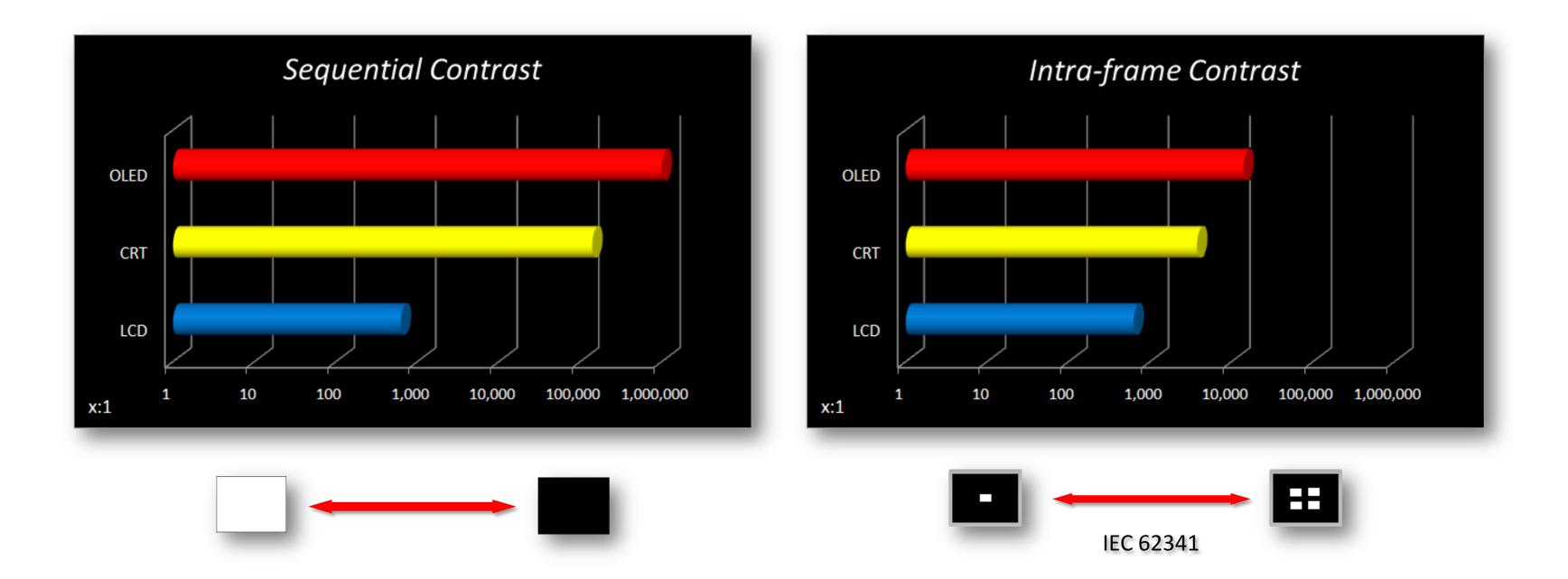






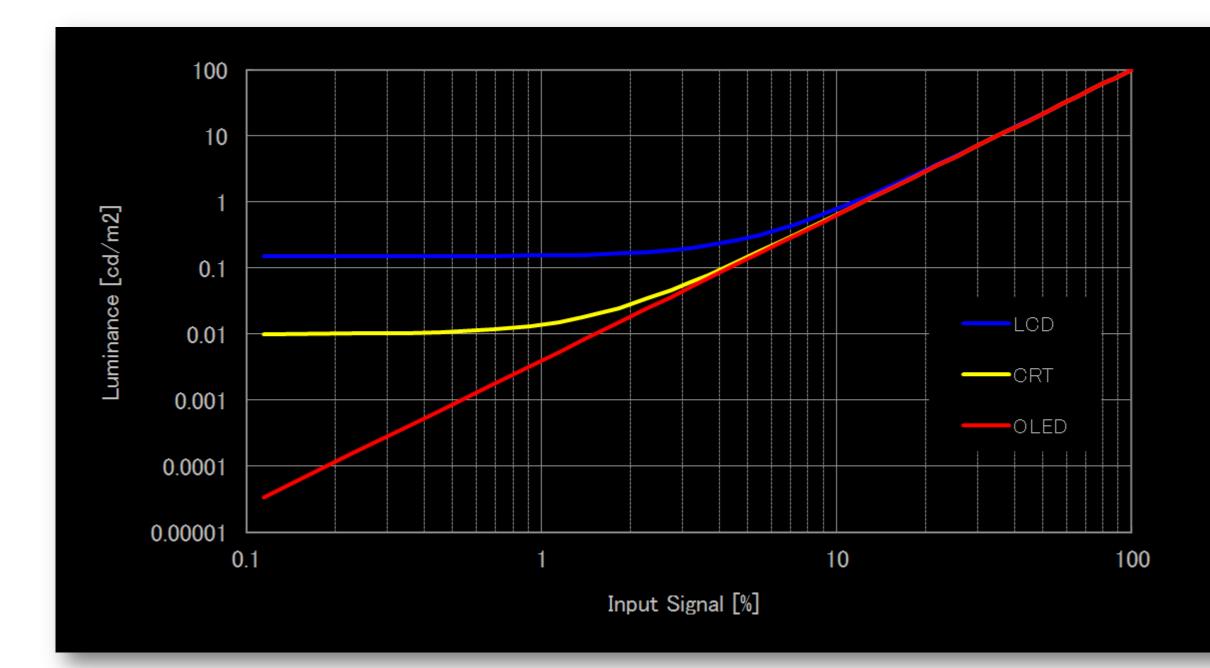
For displays between 20" and 42"





Contrast Performance





Black Performance



OLED

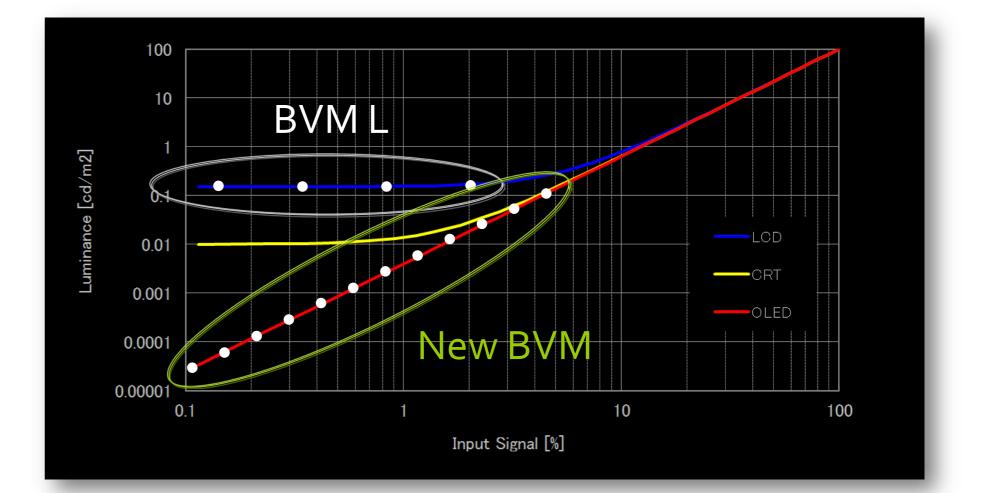


LCD



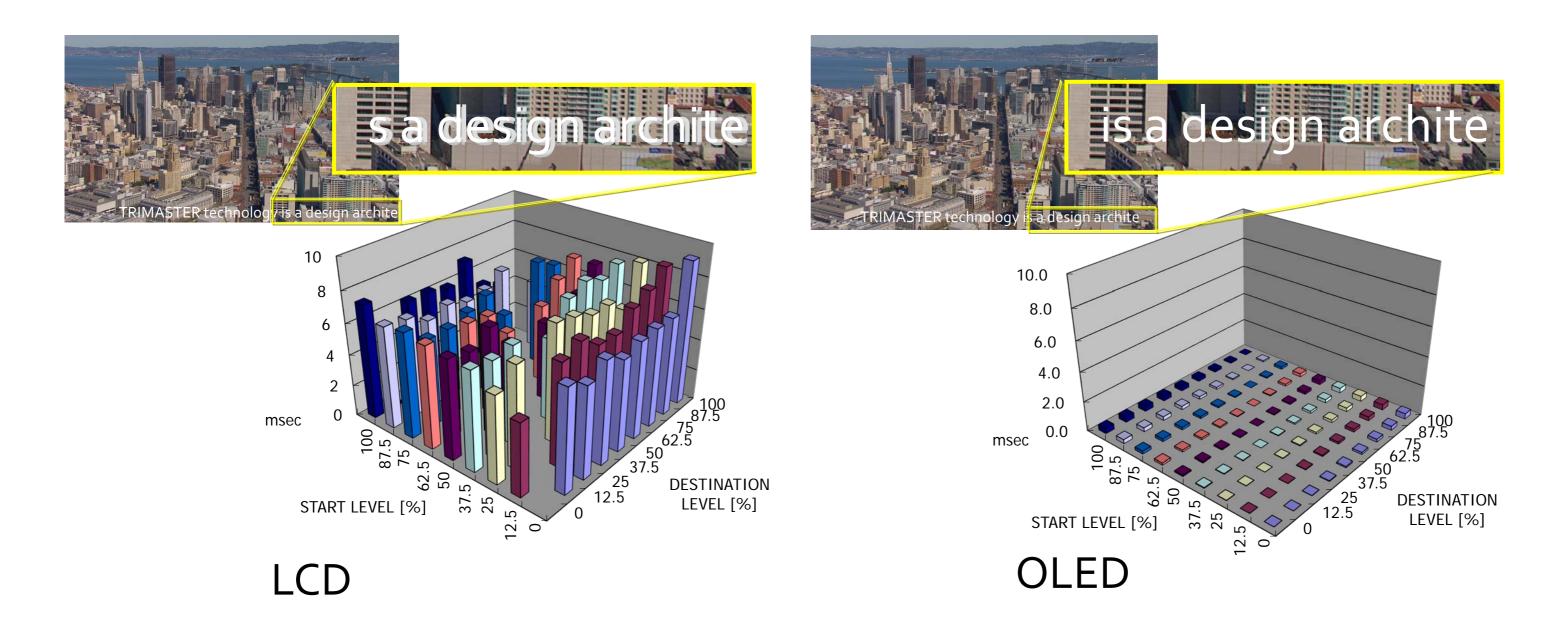
New Signal Processing

- Improved black accuracy
 - Increased process bit depth
- New uniformity correction system
 - 3 Dimensional correction
- More accurate color management system for CRT emulation
- New I/P Conversion system
 - Faster through-put from 11ms to 3ms for 1080/60i



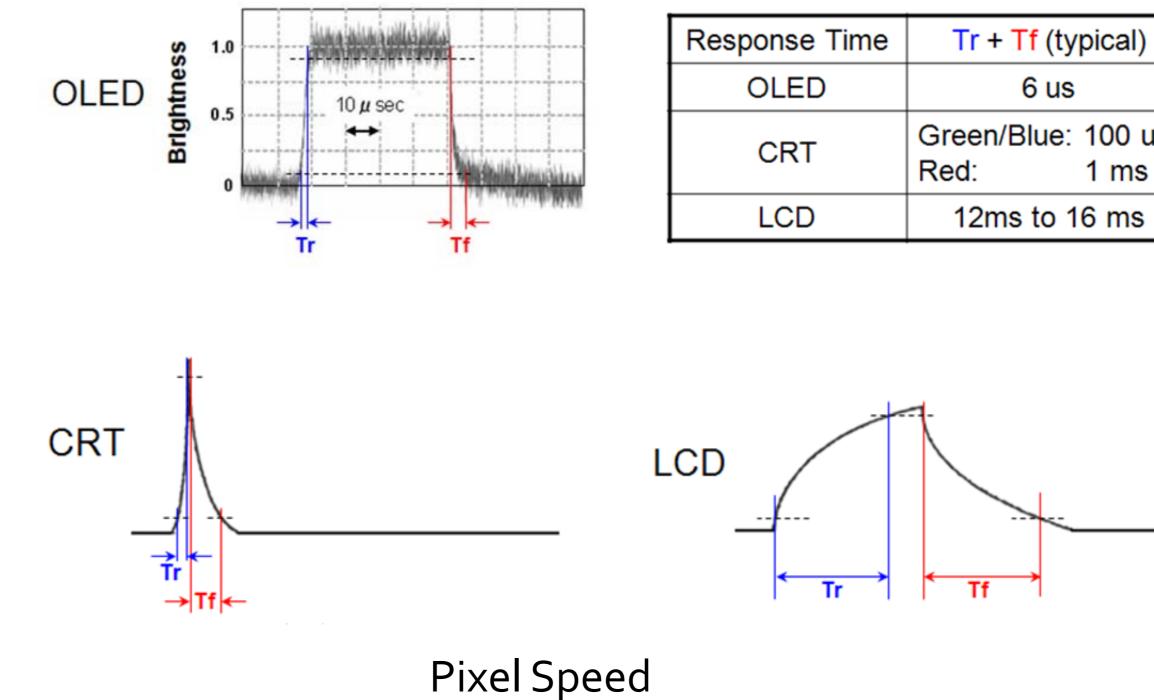






Pixel Speed





Tr + Tf (typical)	
6 us	
Green/Blue: 100 us	
Red: 1 ms	
12ms to 16 ms	



Panel Write Operation

LCD

CRT























Smearing issues No flicker

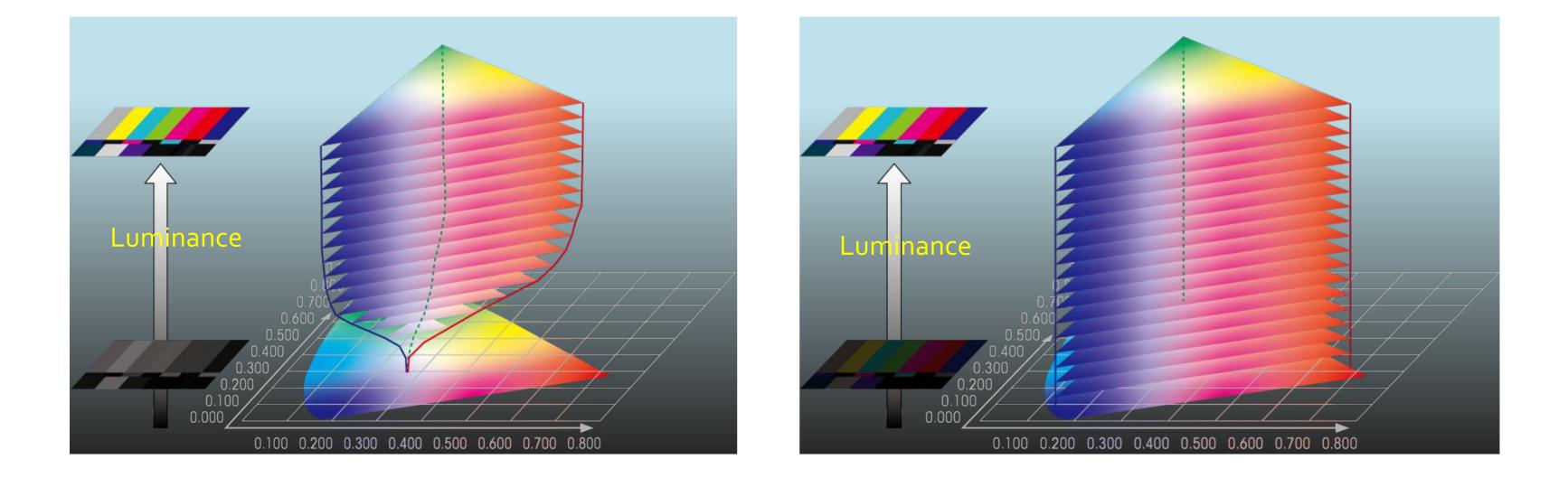


Good motion performance Flicker



Balanced performance





LCD

Gamut Accuracy

OLED



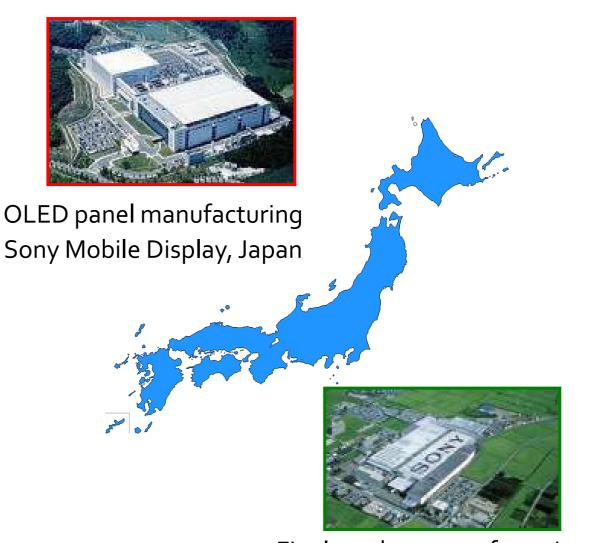
The Latest Panel Design

2009

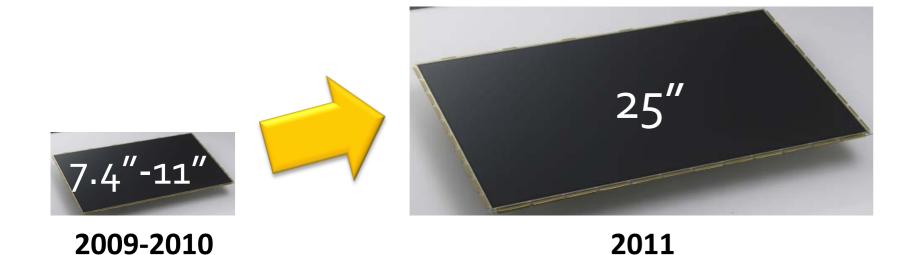
• 7.4 & 11 inch volume production

2011

17 & 25 inch volume production









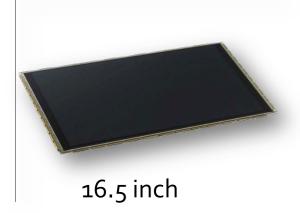
Final product manufacturing Sony EMCS Factory, Japan



The Latest Panel Design

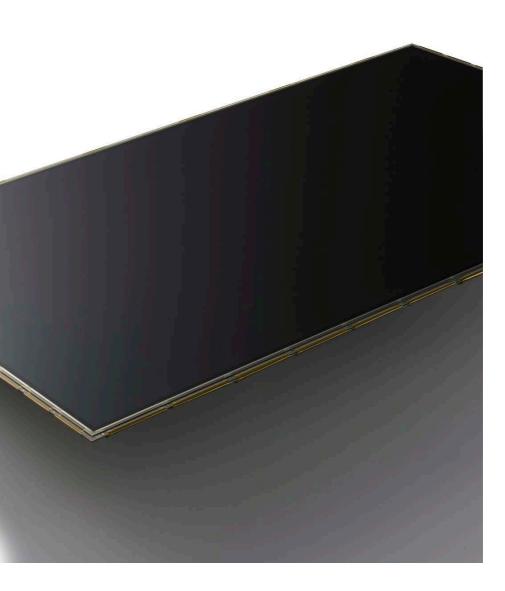
17 inch & 25 inch AMOLED panel

- 16.5 & 24.5 inch diagonal
- 10 bit drivers
- 1920 x 1080 resolution
- Top emission architecture
- P₃ color gamut
- Panel life equal to BVM CRT



24.5 inch







Mechanical Advantages



BVM E250 29 lbs.



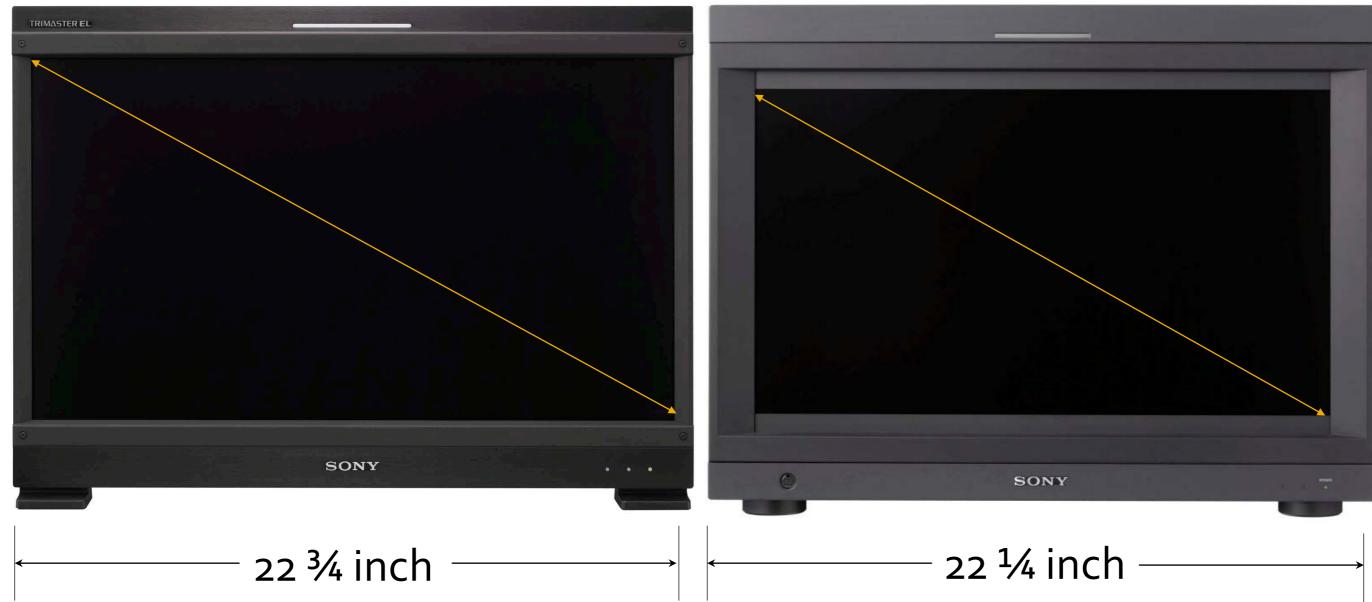


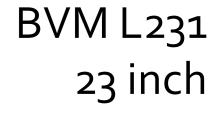
BVM L231 47 lbs.



Mechanical Advantages

BVM E250 25 inch







Resulting Product Lineup

TRIMASTER EL BVM E Series









Resulting Product Lineup

TRIMΔSTER EL BVM F Series







Resulting Product Lineup

TRIMΔSTER EL PVM Series







9







SONY